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(71) Applicant (for all designated States except US): RENSSE-LAER POLYTECHNIC INSTITUTE [US/US]; 110 8th Street, Troy, NY 12180-3590 (US).

(72) Inventors; and

(75) Inventors/Applicants (for US only): AJAYAN, Pulickel [IN/US]; Rensselaer Polytechnic Institute, 110 8th Street, Troy, NY 12180-3590 (US). RYU, Chang, Y. [KR/US]; Rensselaer Polytechnic Institute, 110 8th Street, Troy, NY 12180-3590 (US). CHAKRAPANI, Nirupama [IN/US]; Rensselaer Polytechnic Institute, 110 8th Street, Troy, NY 12180-3590 (US). VISWANATHAN, Gunaranjan [IN/US]; 110 8th Street, Troy, NY 12180-3590 (US). CURRAN, Seamus [IE/US]; Rensselaer Polytechnic Institute, 110 8th Street, Troy, NY 12180-3590 (US).

(74) Agents: MAEBIUS, Stephen, B. et al.; Foley & Lardner, Suite 500, 3000 K Street, N.W., Washington, DC 20007-5101 (US).

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